

**Search Notes**

Application/Control No.

10/804,020

Examiner

Richard H. Kim

Applicant(s)/Patent under  
Reexamination

JEOUNG, HUN

Art Unit

2871

**SEARCHED**

| Class | Subclass | Date | Examiner |
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**INTERFERENCE SEARCHED**

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**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

|  | DATE       | EXMR |
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| East Text Search (349/38,141;349/\$)-<br>JPO,EPO,USPAT,PGPUB-see<br>printout | 12/21/2005 | RHK  |
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